



Attorney's Docket No. 42P17294

Patent

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application of:)

Chau, Robert S et al)

U.S. Serial No: 10/749,196)

Examiner: Blum, David S

Filed: December 30, 2003)

Art Unit: 2813

For: Replacement Gate Flow Facilitating)
High Yield and Incorporation of Etch)
Stop Layers and/or Stressed Films)

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT AND RESPONSE

Dear Sir:

This is in response to the Office Action mailed June 27, 2005. Applicant respectfully requests the Examiner to enter the following amendments and consider the following remarks.

FIRST CLASS CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail with sufficient postage in an envelope addressed to MAIL STOP _____
COMMISSIONER FOR PATENTS, P.O. Box 1450, Alexandria, VA 22313-1450
U.S. Patent and Trademark Office, Washington, D.C. 20231 on October 20, 2005.
Date of Deposit

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Signature

October 20, 2005

Date